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Patent

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#16/COA

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Fabrice Geiger et al.

Application No.: 09/701,065

Filing Date: February 12, 2001

For: Methods For Forming Self-Planarized Dielectric Layer For Shallow Trench Isolation

Assistant Commissioner  
for Patents  
Washington, D.C. 20231

Examiner: Duda, Kathleen

Art Unit: 1756

Confirmation No.: 7160

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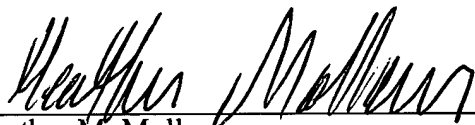
Please change the correspondence address of the above-identified patent application to the following person and address:

**Patent Counsel, MS/2061  
Legal Affairs Dept.  
Applied Materials, Inc.  
P.O. Box 450A  
Santa Clara, CA 95052**

Please update the Patent Office records to reflect the new correspondence address.

Respectfully submitted,  
BLAKELY, SOKOLOFF, TAYLOR & ZAFMAN LLP

Date: 03/26, 2003

  
Heather M. Molleur  
Reg. No. 50,432

Patent Counsel  
Legal Affairs Dept.  
APPLIED MATERIALS, INC.  
P.O. Box 450A  
Santa Clara, CA 95052

Telephone inquiries to:  
Heather M. Molleur  
(408) 720-8300

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